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## IN THE CLAIMS:

A method for removing contaminant particles from a (Currently Amended) substrate surface, comprisi :g:

supporting a substrate in a face up position on a substrate support member,

actuating a piston assembly positioned in a stem of the substrate support member, the actuating cau sing the piston assembly to travel toward the substrate and contact a terminating end, he contact with the terminating end operating to generate a broadband impulse impart ag a broadband impulse to the substrate support member in a direction that is substantially perpendicular to a surface of the substrate, the broadband impulse being of sufficient magnitude to dislodge contamination particles from the surface of the sub trate; and

removing dislodged particles from an area proximate the substrate surface.

The method of claim 1, wherein supporting a substrate comprises 2. (Original) vacuum chucking the substrate to a substrate receiving surface of the substrate support member.

## 3. (Cancelled)

- The n ethod of claim 1, wherein removing dislodged particles 4. (Original) comprises actuating an air knife assembly positioned proximate a perimeter of the substrate support member.
- The n ethod of claim 1, wherein removing dislodged particles 5. (Original) comprises generating a lan inar flow of gas across the substrate surface.
- The riethod of claim 1, wherein removing dislodged particles 6. (Original) comprises generating a reasma above the substrate support member, wherein the plasma is configured to attract dislodged particles.

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- 7. (Original) The mathod of claim 1, wherein removing dislodged particles comprises pumping the dislodged particles into a pumping channel that is circumferential to a perimeter of the substrate support member.
- 8. (Original) The method of claim 1, further comprising analyzing the substrate surface with an inspection station and determining a force to be applied to the substrate that is sufficient to dislodge particles therefrom.
- 9. (Original) The mi thod of claim 8, wherein the analyzing step includes using a metrology station.
- 10. (Currently Amended A method for cleaning contaminants from a substrate surface, comprising:

clamping a substrate to a substrate support member;

generating a broadt and impulse with a broadband actuator device positioned in a stem portion of the substrate support member.

transferring the breadband impulse to a substrate receiving surface of the support member via a substrate reinforcement member positioned between the substrate receiving surface and the stem portion to dislodge particles from the substrate; communicating a broadband impulse to the substrate support member; and

removing dislodged particles from an area proximate the substrate surface with an air knife assembly.

- 11. (Currently Amended The method of claim 10, wherein clamping the substrate comprises vacuu n chucking the substrate to a the substrate receiving surface of the substrate support member.
- 12. (Cancelled)
- 13. (Original) The method of claim 10, wherein generating the broadband impulse comprises actuating a slik able piston assembly longitudinally positioned in the stem

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portion and allowing the piston assembly to contact a terminating end to transfer a broadband impulse to the seem portion.

- 14. The method of claim 10, wherein transferring the broadband (Original) impulse to the substrate receiving member comprises positioning a semi-hemispherical reinforcement member bet leen the substrate receiving member and the stem portion, the semi-hemispherical rainforcement member being configured to transfer the broadband impulse to the substrate receiving member with minimal deflection to the substrate receiving membe .
- 15. The r ethod of claim 14, wherein transferring the broadband (Original) impulse to a substrate receiving surface further comprises forming a plurality of reinforcement ribs into an :inder side of the substrate support member, the plurality of reinforcement ribs being configured to transfer a broadband impulse from the semihemispherical reinforcement member to the substrate receiving member.
- 16. The muthod of claim 10, wherein removing dislodged particles from (Original) the area proximate the substrate surface comprises generating a laminar flow of gas across the substrate surface.
- A met nod for removing contaminant particles from a substrate 17. (Original) surface, comprising:

securing a substrate to a substrate support member with a means for securing;

actuating the substrate support member with a broadband impulse with a means for actuating, the means for actuating being in communication with the substrate support member via a semi-hemispherical reinforcement member; and

removing particles dislodged from the substrate surface with a means for removing.

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- The mi thod of claim 17, whirein securing the substrate comprises (Original) 18. at least one of vacuum chucking the substrate, e-chucking the substrate, and mechanically clamping the ::ubstrate.
- The method of claim 17, wherein actuating the substrate support 19. (Original) member comprises providing a broadband actuator in a stem portion of the substrate support member, the broadband actuator being configured to impart a broadband impulse to the substrate support member.
- 20. The method of claim 17, wherein removing particles dislodged from (Original) the substrate surface comprises actuating an air knife assembly to generate a laminar flow of gas across the subs rate surface.
- The method of claim 17, wherein removing particles dislodged from 21. (Original) the substrate surface con prises generating a plasma above the substrate support member, the plasma being configured to attract dislodged particles.
- The method of claim 17, wherein removing particles dislodged from 22. (Original) the substrate surface comprises providing a circumferential pumping channel surrounding the substrate support member, the circumferential pumping channel being in communication with a pumping device.